

# BIOVIA MATERIALS STUDIO COMPASS

Datasheet



BIOVIA Materials Studio COMPASS is a powerful forcefield that supports atomistic simulations of condensed phase materials. Materials Studio COMPASS stands for Condensed-phase Optimized Molecular Potentials for Atomistic Simulation Studies. It is the first ab initio forcefield that has been parameterized and validated using condensed-phase properties in addition to various ab initio and empirical data for molecules in isolation. Consequently, this forcefield enables accurate and simultaneous prediction of structural, conformational, vibrational, and thermophysical properties, that exist for a broad range of molecules in isolation and in condensed phases, and under a wide range of conditions of temperature and pressure.

The Materials Studio COMPASS forcefield aims to achieve high accuracy in prediction for a broad range of systems. The goal is to be able to predict properties of molecules, both in isolation and in the condensed phase, with an accuracy comparable with experiments. It is an ab initio forcefield because most parameters are initially derived based on ab initio data. Following this step, parameters are optimized to yield good agreement with experimental data. In particular, thermophysical data for molecular liquids and crystals are used to refine the nonbonded parameters by using molecular dynamics simulations.

Another objective of Materials Studio COMPASS development is to systematically extend the coverage so that it includes most of the common organic and inorganic materials that are of interest to the materials researchers. In the latest version of the parameters, COMPASS III <sup>[8]</sup>, the coverage includes the most common organics including drug-like molecules, inorganic small molecules, polymers, some metal ions, metal oxides, metals, solvents including ionic liquids. Many materials specific applications such as lithium ion batteries are also specifically parameterized..

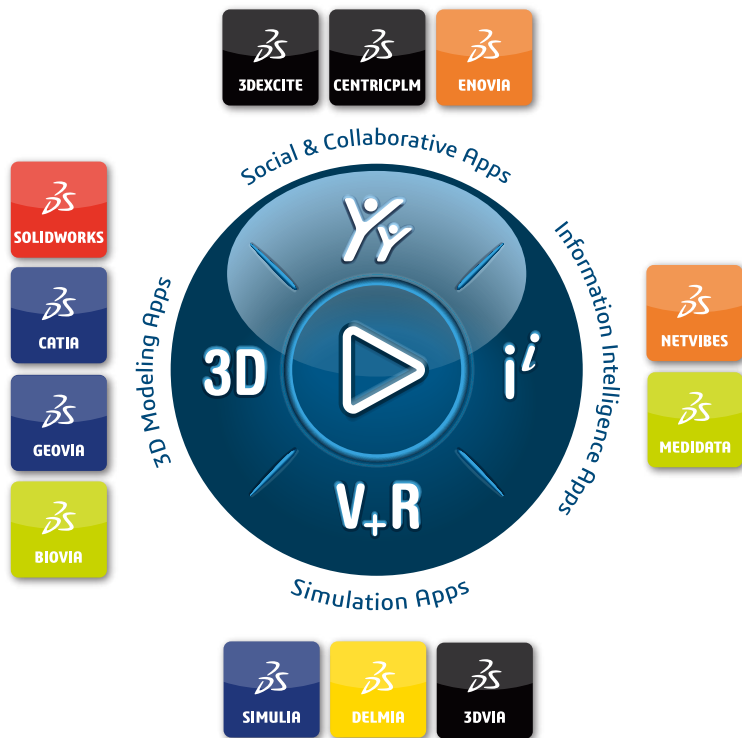
All of the parameters in Materials Studio COMPASS are derived in a consistent manner (as described in reference [8]). so that, in principle, one can often study complex systems containing mixed materials classes.

LEARN MORE

---

## REFERENCES

1. Sun, H. and Rigby, D., "*olysiloxanes: Ab Initio Forcefield and Structural, Conformational and Thermophysical Properties*," *Spectrochimica Acta*, 1997, A153, 1301-1323.
2. Rigby, D., Sun, H., and Eichinger, B. E., "*Computer Simulations of Poly(ethylene oxide): Forcefield, PVT Diagram and Cyclization Behavior*," *Polymer International*, 1997, 44, 311-330.
3. Sun, H., "*COMPASS: An Ab Initio Forcefield Optimized for Condensed-Phase Application-Overview with Details on Alkane and Benzene Compounds*," *J. Phys. Chem.*, 1998, B102, 7338-7364.
4. Sun, H., Ren, P., and Fried, J. R., "*The COMPASS Forcefield: Parameterization and Validation for Phosphazenes*," *Comput. Theor. Polymer Sci.*, 1998, 8, 229-246.
5. Bunte, S.W. and Sun, H., "*Molecular Modeling of Energetic Materials: The Parameterization and Validation of Nitrate Esters in the COMPASS Forcefield*," *J. Phys. Chem.*, 2000, B104, 2477-2489.
6. McQuaid M.J., Sun H., Rigby D., "*Development and validation of COMPASS force field parameters for molecules with aliphatic azide chains*," *J. Comput. Chem*, 2004, 25(1), 61-71.
7. Lifeng Zhao, Lianchi Liu, and Huai Sun, "*Semi-ionic Model for Metal Oxides and Their Interfaces with Organic Molecules*" *J. Phys. Chem. C* 2007, 111, 10610-10617
8. Akkermans, R. L. C., Spenley, N.A. & Robertson, S. H.. 2021 COMPASS III: automated fitting workflows and extension to ionic liquids, *Molecular Simulation*, 47:7, 540-551, DOI: 10.1080/08927022.2020.1808215



## Our 3DEXPERIENCE® platform powers our brand applications, serving 11 industries, and provides a rich portfolio of industry solution experiences.

Dassault Systèmes, the 3DEXPERIENCE Company, is a catalyst for human progress. We provide business and people with collaborative virtual environments to imagine sustainable innovations. By creating 'virtual experience twins' of the real world with our 3DEXPERIENCE platform and applications, our customers push the boundaries of innovation, learning and production.

Dassault Systèmes' 20,000 employees are bringing value to more than 270,000 customers of all sizes, in all industries, in more than 140 countries. For more information, visit [www.3ds.com](http://www.3ds.com).

### Europe/Middle East/Africa

Dassault Systèmes  
10, rue Marcel Dassault  
CS 40501  
78946 Vélizy-Villacoublay Cedex  
France

### Asia-Pacific

Dassault Systèmes K.K.  
ThinkPark Tower  
2-1-1 Osaki, Shinagawa-ku,  
Tokyo 141-6020  
Japan

### Americas

Dassault Systèmes  
175 Wyman Street  
Waltham, Massachusetts  
02451-1223  
USA

**DS DASSAULT SYSTEMES** | The **3DEXPERIENCE®** Company